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DOI: 10.1039/c5ra90075a

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## Correction: Dielectric hysteresis behaviors of polyvinylidene fluoride-based multilayer dielectrics controlled by confined distribution of conductive particles

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Correction for 'Dielectric hysteresis behaviors of polyvinylidene fluoride-based multilayer dielectrics controlled by confined distribution of conductive particles' by Jiaming Zhu *et al.*, *RSC Adv.*, 2015, 5, 65927–65931.

The authors apologise for inserting an incorrect image for Fig. 1 into the proof version of the original manuscript. The correct version of Fig. 1 is shown below.

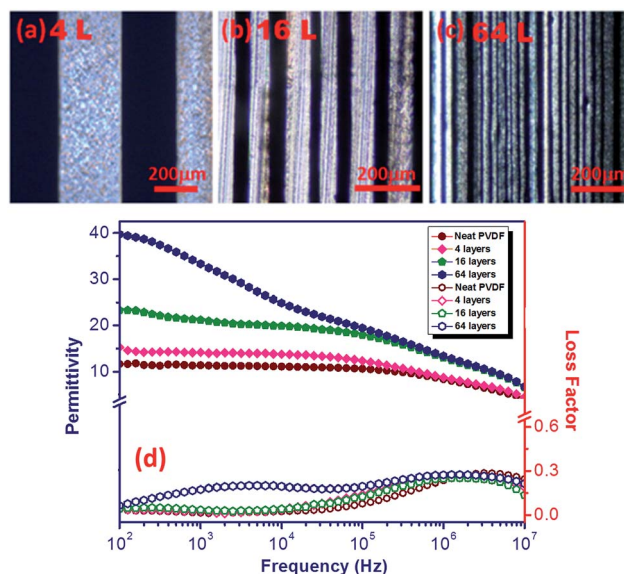


Fig. 1 (a–c) POM images of 4-, 16- and 64-layer PVDF/cPVDF specimens; (d) dielectric permittivity and loss factor of PVDF/cPVDF multilayer dielectrics and neat PVDF as a function of frequency.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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